

Please type a plus sign (+) inside this box →

<p>Substitute for form 1449A/B/PTO</p> <p><b>INFORMATION DISCLOSURE STATEMENT BY APPLICANT</b></p> <p>(Use as many sheets as necessary)</p>				<p><i>Complete if Known</i></p>	
Application Number		Unassigned			
Filing Date		September 16, 2003			
First Named Inventor		Koji KISE			
Group Art Unit		Unassigned			
Examiner Name		Unassigned			
Attorney Docket Number		402786/FUKAMI			
Sheet	1	of	1		

OTHER - NON PATENT LITERATURE DOCUMENTS				
Examiner Initials	Doc. No.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number (s), publisher, city and/or country where published.	Translation	
			Yes	No <sup>++</sup>
CEL	A 4	T. TAKIGAWA, "The Innovation of ULSI Lithography" <i>Science Forum Co. Ltd.</i> , 1995, pp. 222, 1 <sup>st</sup> edition. <i>enable to evaluate foreign language</i>		
CEL	A 5	KISE et al., "Suppression of Secodary Electron Blur By Using Br-Containing Resists In X-Ray Lithography", <i>Journal of Vacuum Science &amp; Tech. B, The Society Through the American Institute of Physics</i> , 2002, pp. 2953-2957, 20(6.)		
CEL	A 6	K. ITOGA et al., "Effect of Secondary Electron from the Substrate In X-Ray Lithography Using Harder Radiation Spectra", <i>Journal of Vacuum Science &amp; Tech. B, The Society Through the American Institute of Physics</i> , 2001, pp. 2439-2443, 19(6.)		

Examiner Signature  Date Considered 3/95

- A concise statement of relevance is being submitted in lieu of a translation. 37 CFR 1.98(a)(3).
- An English-language equivalent/patent, or an English-language abstract, or an English-language version of the search report or action by a foreign patent office in a counterpart foreign application indicating the degree of relevance found by the foreign office is being submitted in lieu of a concise explanation of relevance under 37 CFR 1.98(a)(3).